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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

licant(s): Liu

Application No.: 10/634,964

Filed: 8/5/2003

Title: CHEMICAL MECHANICAL
PLANARIZATION COMPOSITIONS FOR
REDUCING EROSION IN SEMICONDUCTOR

WAFERS

Attorney Docket No.: 02039US

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

RESPONSE

Dear Sir:

In response to the Office Action of July 6, 2005, having a statutory due date of October 6, 2005, please amend this application as follows:

Art Unit:

1765

Examiner:

Patricia A. George